

2224-163P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:

Tatsuya NAKANO

International

Appl. No.:

PCT/JP99/02637 1

Group:

Unassigned

Appln. No.:

09/463,059

Filed:

January 19, 2000

Examiner: UNASSIGNED MAIL ROOM

For:

ACID-SENSITIVE COMPOUND AND RESIN

COMPOSITION FOR PHOTORESIST

LETTER SUBMITTING PAPER BEARING ORIGINAL SIGNATURE

Assistant Commissioner for Patents Washington, DC 20231

April 28, 2000

Sir:

In the above-identified application, a copy of the original executed Declaration and Power of Attorney was submitted to the U.S.P.T.O. on January 19, 2000.

As evidence of authenticity of the copy under 37 C.F.R. § 1.4(d)(2), Applicant submits herewith the original executed Declaration and Power of Attorney, and requests that it be made part of the Prosecution History of the above-identified application

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by being added to the contents of the file wrapper of the aboveidentified application.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fee required under 37 C.F.R. §§ 1.16 or 1.17; particularly, extension of time fees.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

By____Ray

Raymond C. Stewart, #21,066

P.O. Box 747

Falls Church, VA 22040-0747

(703) 205-8000

Attachment

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RCS/EHV:jls

(Rev. 04/19/2000)